

English Language Policy

This document outlines Design School Asia's English language proficiency requirements for admissions

1. English language proficiency
 - 1.1. All programmes at Design School Asia are taught and assessed in the medium of English. Therefore, all applicants must demonstrate they possess at least a minimum standard of English language proficiency. This document sets out our requirements.
 - 1.2. Design School Asia accepts the following English language tests for courses:
 - i. IELTS: 6.0 overall with a minimum of 5.5 in each component; or
 - ii. TOEFL (Paper-Based) with a minimum of 550; or
 - iii. TOEFL (Internet-Based) with a minimum of 79; or
 - iv. SAT (Evidence-Based Reading and Writing) with a minimum of 450.
 - 1.3. English tests must have been taken within the last two years prior to the start date of the course. Applicants whose tests fall outside this timescale will either need to demonstrate how they have kept their English current since the date of the test or retake a suitable English language test.
 - 1.4. Additionally, the School will not normally insist upon an applicant providing any further evidence of their English language ability if (s)he has recently graduated with a degree from a programme in the medium of English.
 - i. Applicants who have successfully completed a degree taught and assessed in English in the two years preceding the date of first enrolment at Design School Asia will be considered for admission.
 - ii. Applicants in possession of such a degree completed more than two years, but not more than five years, preceding the date of first enrolment at Design School Asia will be considered on a case by case basis to assess whether they have sufficient evidence demonstrating their proficiency at the appropriate standard in each skill area (listening, speaking, reading and writing). We may request additional evidence that they have maintained their use of academic English sufficiently since their degree.

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